INFORMATION DISCLOSURE CITATION IN AN APPLICATION (Use several sheets if necessary)	Attorney Docket No.: 8017-1120	Application No.: NEW NONPROVISIONAL
	Applicant: Norio OKADA	
	Filing Date: January 16, 2004	Group Art Unit:

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing date (if appropriate)

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation Yes	Translation No
YY	2001-298028	10/26/2001	JAPAN			*	
YY	2001-156168	6/8/2001	JAPAN			*	
YY	11-269693	10/5/1999	JAPAN			*	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

YY	Kai-Min YIN et al., "OXIDATION OF TA DIFFUSION BARRIER LAYER FOR CU METALLIZATION IN THERMAL ANNEALING", 741-20005,, Thin Solid Films 388 (2001)27-33

EXAMINER: Yvonne A. Hurley DATE CONSIDERED 5/7/04

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

* Abstract provided for the Examiner's convenience

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